

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

October 16, 2025

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

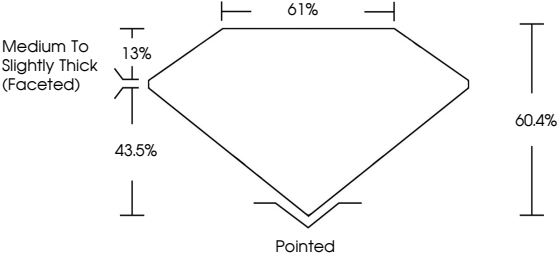
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

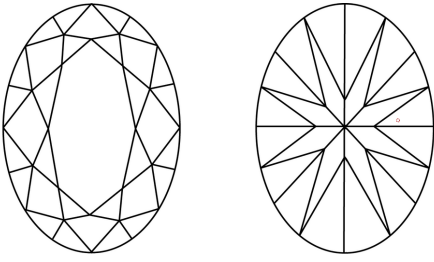
LG743565970

Report verification at igi.org

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

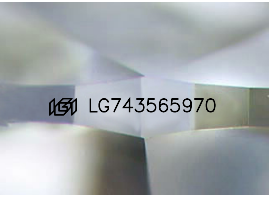
Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

CLARITY

D	E	F	G	H	I	J	Faint	Very Light	Light
FL	IF	VS 1-2	VS 1-2	SI 1-2	I 1-3				
Flawless	Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included				

Sample Image Used



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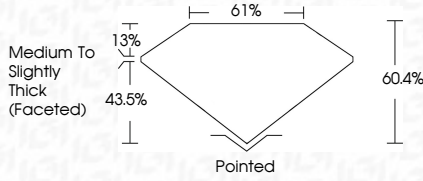
EXCELLENT

EXCELLENT

NONE

IGI LG743565970

PROPORTIONS



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EXCELLENT

EXCELLENT

NONE

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OVAL BRILLIANT

11.07 X 7.75 X 4.68 MM

2.51 CARATS

D

VVS 1

60.4%

61%

Medium to Slightly Thick (Faceted)

Pointed



EXCELLENT

EXCELLENT

NONE


IGI LG743565970

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